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Atty Docket No. Serial No. **OPE-002** 09/556,285 INFORMATION DISCLOSURE CITATION Applicant G. Taylor PAGE 1 OF 2 Filed Group 2811 April 24, 2000 **US PATENT DOCUMENTS** Document No. Date Name Class Subclass Filing date if Examiner approp. Initials Already of 4.683.484 07/28/1087 357 16 Derkite, Jr. 29M 6,351,001 02/26/2002 Stevens et al. 257 223 C D E F G Н Т J Κ FOREIGN PATENT DOCUMENTS Country Class Subclass Translation Examiner Document No. Date Yes No Initials OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.) Gunapala et al., "Quantum Well Infrared Photodetector (QWIP) Focal Plane Arrays," Semiconductors and Semimetals series, Vol. 62, 1999 Song et al., "A Resistive-Gate Al_{0.3}Ga_{0.7}As/GaAs 2DEG CCD with High Charge-Transfer Efficiency at 1 GHz," IEEE Trans. On Elec. Dev., Vol. 38, No. 4, April 1991, pp. 930-932 Bakker et al., "The Tacking CCD: A New CCD Concept," IEEE Trans. On Elec. Dev., Vol. 38, No. 5, May 1991, pp. 1193-1200 DATE CONSIDERED

12 MARCH 2004 **EXAMINER** G. MUNSON



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